UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.

: 6,911,399 B2

Page 1 of 1

DATED

: September 19, 2003

INVENTOR(S): Wei Liu and David Mui

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 2,

Line 15, change "to leave" to -- gas mixture to etch --. Line 39, change "integrate" to -- integrated --.

Column 8,

Line 7, change "claim 3" to -- claim 1 --. Line 14, change "scorn" to -- sccm --.

Signed and Sealed this

Eleventh Day of April, 2006

JON W. DUDAS
Director of the United States Patent and Trademark Office